

4

4.23

A recently discovered semiconductor has $N_c = 10^{19} \text{ cm}^{-3}$, $N_v = 5 \times 10^{18} \text{ cm}^{-3}$, and $E_g = 2 \text{ eV}$. If it is doped with 10^{17} donors (fully ionized), calculate the electron, hole, and intrinsic carrier concentrations at 627°C . Sketch the simplified band diagram, and specify the value of E_F and E_i with respect to the band edges. If we apply 5 V across a piece of this semiconductor $8 \mu\text{m}$ long, what is the current? The piece is $2 \mu\text{m}$ wide and $1.5 \mu\text{m}$ thick. The diffusion coefficient of holes and electrons is $25 \text{ cm}^2/\text{s}$ and $75 \text{ cm}^2/\text{s}$, respectively.

✓ Answer ✓

$$n_i = \sqrt{N_c N_v} e^{-E_g/2kT}$$
$$n_i = 1.784 \times 10^{13} \text{ cm}^{-3}$$

$$n_0 \approx 10^{17}$$

$$n_0 p_0 = n_i^2$$

$$p = \frac{n_i^2}{n}$$

$$p = 3.18 \times 10^9$$

$$n_0 = n_i e^{(E_F - E_i)/kT}$$

$$E_F - E_i = 0.6696 \text{ eV}$$

Where E_i is the center of the edges of the band

$$J = q(p\mu_p + n\mu_n)\varepsilon$$

$$J = \frac{q}{kT}(pD_p + nD_n)\frac{E}{L}$$

$$J = 96674 \frac{\text{A}}{\text{cm}^2}$$

$$I = JA = 2.9 \text{ mA}$$

5.9

An abrupt Si junction (area = 0.0001 cm^2) has the following parameters:

$$\text{n-side: } N_d = 5 \times 10^{17} \text{ cm}^{-3}$$

$$\text{p-side: } N_a = 10^{17} \text{ cm}^{-3}$$

Draw and label the band diagram, and calculate the difference between the Fermi level and the intrinsic Fermi level on both sides. Calculate the built-in potential at the junction in equilibrium and the depletion width. What is the total number of exposed acceptors in the depletion region?

✓ **Answer**

$$n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$$

On the n-side

$$n_0 = n_i e^{(E_F - E_i)/kT}$$

$$E_F - E_i = 0.4486 \text{ eV}$$

On the p-side

$$p_0 = n_i e^{(E_i - E_F)/kT}$$

$$E_i - E_F = 0.4070 \text{ eV}$$

$$V_0 = \frac{kT}{q} \ln \left(\frac{N_a N_d}{n_i^2} \right)$$

$$V_0 = 0.8556 \text{ V}$$

$$W = \sqrt{\frac{2\epsilon V_0}{q} \left(\frac{N_a + N_d}{N_a N_d} \right)}$$

$$W = 1.1577 \times 10^{-5} \text{ cm}$$

$$x_{p0} = W \frac{N_d}{N_a + N_d}$$

$$x_{p0} = 9.65 \times 10^{-6}$$

5.15

Boron is implanted into an n-type Si sample ($N_d = 10^{16} \text{ cm}^{-3}$), forming an abrupt junction of square cross section with area $= 2 \times 10^{-3} \text{ cm}^2$. Assume that the acceptor concentration in the p-type region is $N_a = 4 \times 10^{18} \text{ cm}^{-3}$. Calculate V_0 , x_{n0} , x_{p0} , Q_+ , and E_0 for this junction at equilibrium (300 K). Sketch ϵ and the charge density to scale, as in Fig. 5–12.

✓ **Answer**

$$A = 2 \times 10^{-3} \text{ cm}^2$$

$$N_d = 10^{16} \text{ cm}^{-3}$$

$$N_a = 4 \times 10^{18} \text{ cm}^{-3}$$

$$V_0 = \frac{kT}{q} \ln \left(\frac{N_a N_d}{n_i^2} \right)$$

$$V_0 = 0.8498 \text{ V}$$

$$W = \sqrt{\frac{2\epsilon V_0}{q} \left(\frac{N_a + N_d}{N_a N_d} \right)}$$

$$W = 3.335 \times 10^{-5} \text{ cm}$$

$$x_{n0} = W \frac{N_a}{N_a + N_d}$$

$$x_{n0} = 3.327 \times 10^{-5}$$

$$x_{p0} = W \frac{N_d}{N_a + N_d}$$

$$x_{p0} = 8.316 \times 10^{-8}$$

$$Q_+ = qA x_{n0} N_d = qA x_{p0} N_a$$

$$Q_+ = 1.06 \times 10^{-10}$$

$$\varepsilon_0 = -\frac{q}{\epsilon} x_{n0} N_d$$

$$\varepsilon_0 = -50966 \frac{\text{V}}{\text{cm}}$$